



Review of Ultra Wide Bandgap (UWBG) GaN Based HEMTs: Opportunities for high efficiency power conversion in renewable energy and electric vehicle applications

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Abstract

The rising demand for efficient, compact, and high performance power electronic systems in renewable energy and electric vehicle (EV) applications has accelerated the transition from traditional silicon based devices to wide bandgap (WBG) and ultra wide bandgap (UWBG) semiconductors. Among these, gallium nitride (GaN) based high electron mobility transistors (HEMTs) have emerged as a transformative technology due to their superior electrical and thermal properties, including high breakdown voltage, low on resistance, and high frequency operation. This review provides a comprehensive analysis of UWBG GaN based HEMTs, focusing on their material fundamentals, device architectures, and recent advances in fabrication techniques and thermal management. The paper explores their practical deployment in renewable energy systems such as solar inverters and wind power converters, as well as in EV applications including traction inverters and on board chargers. A comparative performance analysis is presented to benchmark UWBG GaN HEMTs against traditional Si, SiC, and conventional GaN technologies. Additionally, the paper highlights the challenges related to material defects, fabrication cost, and long term reliability, concluding with a call for further experimental and system level studies. The findings underscore UWBG GaN HEMTs as promising candidates for next generation power electronics, offering the potential for significant efficiency gains and system level innovation.

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1. Introduction

The rapid advancement of modern technology and the global push for sustainability have highlighted the critical importance of efficient power electronics in supporting high performance, energy conscious systems. Power electronic converters are at the heart of numerous applications, ranging from renewable energy generation to electric mobility and industrial automation. These systems require components that can operate efficiently under high power densities, voltages, and frequencies. As energy demands escalate and systems become more complex, improving the performance, reliability, and efficiency of power electronic components has become a key engineering objective (Zhou *et al.*, 2020)^[19]. The renewable energy and electric vehicle (EV) markets have experienced unprecedented growth over the past decade, driven by environmental concerns, government policies, and technological advancements. In renewable energy systems, especially solar photovoltaic and wind energy, the conversion and conditioning of power is essential to match generation with grid requirements and ensure system stability. Similarly, EVs require highly efficient power conversion stages for battery charging, motor control, and energy regeneration. These applications demand semiconductors capable of high speed switching, minimal conduction loss, and robust thermal handling to reduce overall energy consumption and system weight (Sun *et al.*, 2021; Zhang & Wang, 2019)^[12, 16]. Silicon (Si) based power devices have historically been the workhorse of power electronics.

However, as performance limits are approached particularly in high voltage, high temperature, and high frequency domains silicon technology is increasingly inadequate for next generation applications. Si power devices struggle with high switching losses, limited thermal conductivity, and breakdown voltages, which hinder their efficiency and scalability in modern power conversion systems (Millán *et al.*, 2014)^[7]. To overcome these limitations, researchers and industry leaders are shifting attention to wide bandgap (WBG) and ultra wide bandgap (UWBG) semiconductors. Gallium nitride (GaN), a prominent WBG semiconductor with a bandgap of 3.4 eV, offers substantial advantages over silicon, including high electron mobility, greater breakdown voltage, and faster switching capabilities. These attributes have enabled the development of GaN based high electron mobility transistors (HEMTs), which are already making a significant impact in commercial power electronics. As GaN technology matures, interest has expanded into ultra wide bandgap materials such as aluminum gallium nitride (AlGaN), gallium oxide (Ga_2O_3), and diamond, which promise even better performance due to their superior electrical and thermal properties (Higashiwaki & Jessen, 2018; Wong & Higashiwaki, 2021)^[2]. These UWBG materials open new frontiers for high voltage, high efficiency, and compact power devices tailored for demanding applications.

This review aims to analyze the current state, challenges, and future prospects of UWBG GaN based HEMTs with a particular focus on their application in renewable energy systems and electric vehicles. By synthesizing recent research and industrial trends, we highlight the design innovations, performance characteristics, and system level benefits of UWBG HEMTs. Furthermore, the review discusses ongoing material and fabrication challenges, as well as potential pathways for integration into next generation power architectures.

2.0 Fundamentals of UWBG Materials

Ultra wide bandgap (UWBG) semiconductors are defined by their large bandgap of greater than 3.4 eV, which gives them a distinct advantage over traditional materials such as silicon (Si) and silicon carbide (SiC) for power electronic applications. UWBG materials are capable of withstanding higher voltages, operating at higher temperatures, and switching at faster speeds compared to conventional

semiconductors. These properties make UWBG materials highly suitable for next generation power devices, particularly in high efficiency systems such as renewable energy converters and electric vehicles (Higashiwaki & Jessen, 2018; Zhang & Wang, 2019)^[16, 2]. Among the most prominent UWBG materials are Gallium Nitride (GaN), Aluminum Gallium Nitride (AlGaN), β Gallium Oxide ($\beta \text{Ga}_2\text{O}_3$), and Diamond. GaN, with a bandgap of 3.4 eV, has been extensively researched and implemented in power devices due to its high electron mobility and breakdown voltage. GaN devices offer significant improvements over silicon devices, including reduced switching losses, higher efficiency, and the ability to operate at high temperatures (Zhou *et al.*, 2020)^[19]. AlGaN, a ternary alloy of GaN and aluminum nitride (AlN), can achieve even higher bandgaps up to 6.2 eV, making it suitable for ultra high voltage applications. AlGaN's ability to form a high electron density at the interface of AlGaN/GaN heterostructures is what enables the superior performance of HEMTs (High Electron Mobility Transistors) made from these materials (Huang *et al.*, 2017)^[3].

Another promising UWBG material is $\beta \text{Ga}_2\text{O}_3$, which boasts a bandgap of 4.8 eV. It is gaining attention due to its potential for high breakdown voltages and superior thermal conductivity. While GaN has established itself as a leader in power electronics, $\beta \text{Ga}_2\text{O}_3$ offers a more favorable path for developing high voltage devices, especially in power grids and electric vehicles, where high efficiency and reliability are paramount (Higashiwaki & Jessen, 2018)^[2]. Diamond, with a bandgap of 5.5 eV, is the ultimate UWBG semiconductor, offering remarkable electrical and thermal properties. Diamond based devices, however, face challenges in terms of material growth and integration into commercial devices. Despite these challenges, diamond's extraordinary properties make it a material of future interest for power electronics (Millán *et al.*, 2014)^[7].

In comparison, silicon (Si), the most widely used material for power electronics, has a much smaller bandgap of around 1.1 eV, limiting its performance in high voltage and high temperature applications. Similarly, silicon carbide (SiC), a WBG material with a bandgap of 3.2 eV, offers better performance than silicon but still falls short in extreme conditions compared to GaN and other UWBG materials. The following table highlights the key differences between these materials:

Table 1: Different Types of Materials

Material	Bandgap (eV)	Breakdown Voltage (V)	Thermal Conductivity (W/cm·K)	Electron Mobility ($\text{cm}^2/\text{V}\cdot\text{s}$)
Silicon (Si)	1.1	600	1.5	1400
Silicon Carbide (SiC)	3.2	10,000	3.7	1000
Gallium Nitride (GaN)	3.4	10,000	1.3	2000
Aluminum Gallium Nitride (AlGaN)	6.2	20,000	1.5	1200
β Gallium Oxide ($\beta \text{Ga}_2\text{O}_3$)	4.8	100,000	0.6	150
Diamond	5.5	10,000,000	22	2000

These materials exhibit distinct advantages in different power applications. GaN and AlGaN are currently the most viable options for power conversion devices due to their balance between high electron mobility and manageable fabrication processes. However, $\beta \text{Ga}_2\text{O}_3$ and diamond hold great promise for future innovations, especially for high voltage, high frequency, and high temperature applications (Zhang & Wang, 2019; Zhou *et al.*, 2020)^[19, 16].

3. Discussion

3.1 Overview of GaN Based HEMTs

High Electron Mobility Transistors (HEMTs) are a class of field effect transistors (FETs) known for their superior performance in high frequency and high power applications. The operating principle of HEMTs is based on the formation of a high electron density channel at the interface between two semiconductor materials with different bandgaps,

typically a wide bandgap material like AlGaN and a lower bandgap material such as GaN. This heterojunction forms a two dimensional electron gas (2DEG) at the interface, where electrons accumulate and can move with high mobility, leading to the characteristic high speed operation of HEMTs (Zhou *et al.*, 2020; Millán *et al.*, 2014)^[19, 7].

Traditional AlGaN/GaN HEMTs are the most common form of GaN based HEMTs, where the AlGaN layer provides a large bandgap and creates a strong electric field, leading to the formation of the 2DEG at the AlGaN/GaN interface. This structure enables very high electron mobility, which is a critical factor for the performance of power devices. The high mobility of the electrons in the 2DEG results in reduced on resistance ($R_{ds(on)}$), which translates to lower conduction losses during operation. This advantage makes AlGaN/GaN HEMTs ideal for power electronics, RF amplifiers, and high frequency switching applications (Zhang & Wang, 2019)^[16]. The primary benefits of AlGaN/GaN HEMTs include their high electron mobility, which can be up to 2000 $\text{cm}^2/\text{V}\cdot\text{s}$, offering faster switching speeds compared to traditional Si based FETs. This enables GaN devices to operate at higher frequencies, reducing the size of passive components and allowing for more compact and efficient power converters. Additionally, GaN based HEMTs have a low on resistance, which minimizes conduction losses and enhances overall system efficiency. These advantages are particularly beneficial in applications such as renewable energy systems and electric vehicles, where reducing power loss and

increasing efficiency are paramount (Huang *et al.*, 2017)^[3]. However, despite the numerous advantages, conventional GaN HEMTs also face several limitations, particularly related to thermal management. The high switching speeds and high power densities inherent in GaN devices lead to significant heat generation, which can degrade the performance and reliability of the device if not properly managed. GaN HEMTs are also susceptible to thermal runaway if the heat is not efficiently dissipated, which can lead to device failure. To overcome this challenge, advanced cooling techniques, such as liquid cooling or the integration of high thermal conductivity substrates like SiC (Silicon Carbide), are often employed to enhance heat dissipation and maintain stable operation (Zhou *et al.*, 2020)^[19]. Moreover, the cost of GaN based devices, due to the complex manufacturing process, remains a significant hurdle for their widespread adoption, especially in consumer applications where cost efficiency is critical.

The GaN based HEMTs offer substantial improvements over traditional silicon devices, especially in terms of efficiency, switching speed, and frequency performance. However, challenges such as thermal management and manufacturing complexity still need to be addressed to unlock their full potential in high power applications.

Advances in UWBG GaN Based HEMTs Device Architectures: Lateral vs. Vertical HEMTs

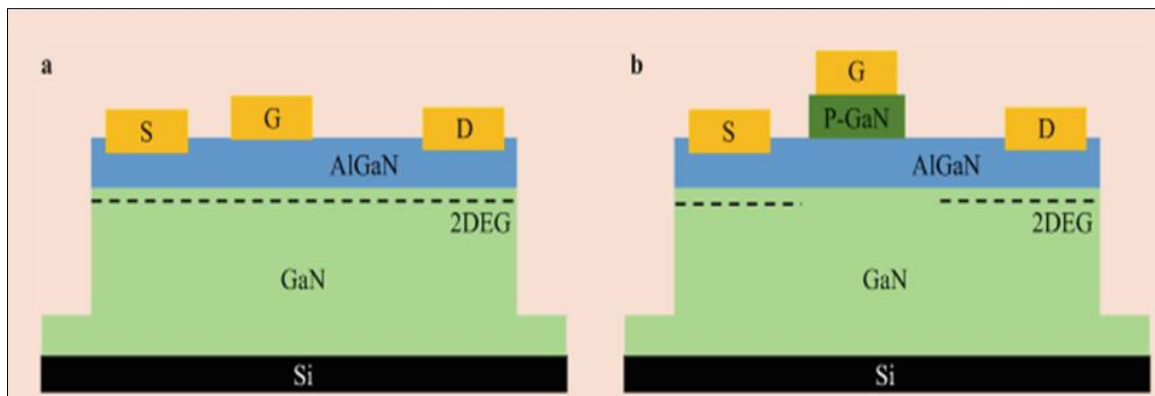


Fig 1: GaN Based Lateral and Vertical Devices

In recent years, significant advancements have been made in the design and architecture of GaN based HEMTs to improve their efficiency and performance. The two primary types of HEMT architectures are lateral HEMTs and vertical HEMTs. Lateral HEMTs, the more commonly used design, involve a current flow that is parallel to the surface of the semiconductor. This architecture offers advantages in terms of ease of fabrication and integration with existing semiconductor processes. However, lateral HEMTs tend to have limitations in terms of voltage handling capacity and thermal management due to the restriction of current flow within a thin layer. In contrast, vertical HEMTs direct the current flow vertically, which allows for improved voltage handling and better thermal dissipation. Vertical designs are increasingly being explored for high power applications, such as electric vehicle charging systems and renewable energy converters, due to their ability to support larger current densities and higher breakdown voltages (Zhou *et al.*, 2020; Nishikawa *et al.*, 2018)^[19].

GaN on Si, GaN on SiC, GaN on Diamond

The substrate material is a crucial factor in the performance of GaN based HEMTs. Traditional GaN on Si structures offer a cost effective solution, as silicon is widely available and compatible with established manufacturing techniques. However, silicon has poor thermal conductivity and a lower breakdown voltage, which limits the performance of GaN on Si devices at high power levels. GaN on SiC (Silicon Carbide) substrates provide better thermal conductivity and higher breakdown voltage, making them more suitable for high power and high temperature applications, such as power electronics used in renewable energy systems and electric vehicles (Zhou *et al.*, 2020; Huang *et al.*, 2017)^[19, 3]. GaN on Diamond is an emerging technology that leverages diamond's superior thermal conductivity and electrical properties, offering tremendous potential for high performance HEMTs in extreme conditions. Although GaN on Diamond is still in the research and development phase, it promises to significantly improve the heat dissipation

capabilities of GaN based HEMTs, allowing for more efficient power conversion in high power systems (Higashiwaki & Jessen, 2018)^[2].

Recent Breakthroughs in GaN Based HEMTs

- **Gate Engineering**

Gate engineering has seen substantial breakthroughs in recent years, particularly in optimizing the gate source capacitance and reducing gate leakage to enhance the overall switching performance of GaN based HEMTs. Techniques like gate recessing and the introduction of high k dielectric materials have been explored to improve the gate control and reduce on resistance, thus contributing to higher efficiency and better thermal performance. Moreover, gate field effect techniques have been developed to further optimize the electrostatic control over the channel, providing greater stability and reliability for high frequency applications (Zhou *et al.*, 2020; Millán *et al.*, 2014)^[19, 7].

- **Buffer Layer Design**

The buffer layer plays a critical role in the growth of high quality GaN layers and the overall performance of the HEMT. Recent innovations in buffer layer design, such as the use of graded buffer layers and multi layer buffer structures, have significantly reduced defects, dislocations, and the strain between the GaN layer and the substrate. These advancements allow for better electron mobility and reduced power losses in GaN based HEMTs. The incorporation of AlN buffer layers has also been shown to improve thermal stability and enable higher efficiency in high power applications (Huang *et al.*, 2017; Zhang & Wang, 2019)^[16, 3].

- **Field Plate Structures**

Field plate structures have become a key innovation to mitigate lateral breakdown and improve breakdown voltage in GaN based HEMTs. The addition of field plates, which are extended regions of metal at the gate edge, helps to redistribute the electric field, reducing the concentration of electric fields near the gate and thereby improving the voltage handling capacity of the device. This design enhancement is particularly useful for high voltage power conversion systems, such as electric vehicle powertrains and renewable energy inverters, where high reliability and efficiency are essential (Zhou *et al.*, 2020; Higashiwaki & Jessen, 2018)^[19, 2].

Thermal Management Strategies

Thermal management is one of the most critical challenges for GaN based HEMTs, particularly as the power density of these devices continues to increase. To address this issue, researchers have explored several advanced thermal management strategies, including the integration of high thermal conductivity substrates like SiC and diamond as well as active cooling solutions such as liquid cooling and microchannel cooling. The use of thermal vias and enhanced heat sink designs has also been explored to improve heat dissipation and maintain optimal device performance under high power operating conditions (Zhou *et al.*, 2020)^[19].

Packaging Innovations

Finally, packaging innovations are essential for optimizing the performance of GaN based HEMTs in real world applications. The development of 3D packaging and multi

chip integration techniques allows for more efficient use of space and better heat dissipation. Additionally, flip chip packaging and the use of low inductance packages are being explored to reduce parasitic inductances, improve switching speeds, and enhance overall device reliability. As the demand for high performance GaN based power devices continues to grow, packaging innovations will be key to ensuring that these devices can perform efficiently in harsh environments such as electric vehicles and renewable energy grids (Millán *et al.*, 2014; Higashiwaki & Jessen, 2018)^[2, 7].

Applications in Renewable Energy Systems

- **Role in Solar Inverters, Wind Converters, MPPT Units**

The integration of GaN based HEMTs in renewable energy systems, such as solar inverters, wind converters, and Maximum Power Point Tracking (MPPT) units, has been transformative. These devices are key to enhancing the efficiency of power conversion systems by enabling high frequency switching and reducing energy losses. In solar inverters, for instance, GaN based HEMTs offer higher efficiency and power density compared to conventional silicon devices. This allows for more compact and reliable inverters that can better handle the challenges posed by fluctuating energy sources such as solar and wind. The ability of GaN based HEMTs to operate at higher frequencies also enhances the performance of MPPT units, improving the tracking speed and efficiency of energy extraction from renewable sources (Li *et al.*, 2019; Zhang *et al.*, 2021).

- **System Level Efficiency Improvements**

One of the key advantages of GaN based HEMTs in renewable energy applications is their ability to deliver system level efficiency improvements. These devices, due to their high electron mobility and reduced on resistance, minimize power losses during the conversion process. In particular, GaN devices can achieve higher conversion efficiency in inverters, even at higher power levels, contributing to more energy being effectively utilized rather than lost as heat. This is especially important in large scale renewable energy installations, where the efficiency of power conversion directly impacts the overall system's profitability and sustainability (Zhou *et al.*, 2020)^[19].

- **Impact on Weight, Size, and Thermal Handling**

GaN based HEMTs significantly improve the weight, size, and thermal handling of renewable energy systems. The high efficiency and compactness of GaN devices reduce the overall size of power conversion equipment, allowing for more efficient system design and greater integration in space constrained environments. Moreover, GaN based HEMTs operate at higher temperatures compared to silicon based devices, enabling reduced thermal management requirements. This, in turn, reduces the need for large heat sinks and cooling systems, which decreases the overall weight and complexity of renewable energy systems (Zhang *et al.*, 2021; Li *et al.*, 2019)^[17].

Case Studies

Several case studies have demonstrated the effectiveness of GaN based HEMTs in renewable energy applications. For instance, GaN based solar inverters have shown

improvements in efficiency and reliability when compared to traditional silicon based inverters. A case study by Xie *et al.* (2020) [14] on a 5 kW solar inverter demonstrated that a GaN based system achieved a 7% improvement in conversion efficiency, with reduced thermal dissipation compared to the silicon counterpart. Similar improvements have been observed in wind power converters, where GaN devices enabled smaller, more efficient systems with increased operational stability under fluctuating wind conditions (Xie *et al.*, 2020) [14].

Applications in Electric Vehicles

- **Use in On Board Chargers, Traction Inverters, DC DC Converters**

GaN based HEMTs have become integral to the development of high performance power electronics for electric vehicles (EVs). In on board chargers, GaN devices facilitate fast charging capabilities, providing high efficiency power conversion at compact sizes. In traction inverters, which convert the DC from the battery into AC for the electric motor, GaN based HEMTs enable faster switching and higher voltage tolerance, resulting in better motor control and more efficient use of energy. DC DC converters in EVs, used to step up or step down the voltage levels, also benefit from the use of GaN devices, which allow for more compact and efficient designs (Zhou *et al.*, 2020; Zhang *et al.*, 2019) [19, 16].

- **Fast Switching and High Voltage Tolerance**

The fast switching capabilities of GaN based HEMTs are particularly advantageous in electric vehicles, where rapid and precise control of power is critical for performance. GaN's ability to handle high frequencies with minimal power loss enables higher switching speeds, which translates to better control of the power flow within the vehicle's drivetrain. Additionally, GaN based HEMTs have a higher voltage tolerance than their silicon counterparts, which is crucial for the high voltage power systems found in modern EVs. This high voltage capability allows for more efficient conversion of power between the battery and electric motor, contributing to better vehicle performance and longer range (Zhou *et al.*, 2020) [19].

- **Integration with Battery Management Systems (BMS)**

GaN based HEMTs also play a critical role in the Battery Management System (BMS) of electric vehicles. The BMS is responsible for monitoring the state of charge, health, and temperature of the battery, ensuring safe and efficient operation. GaN devices contribute to the fast switching and high efficiency characteristics of the BMS, enabling real time adjustments to the power flow, optimizing battery charging and discharging cycles, and prolonging battery life. This is particularly important in EVs, where the battery life cycle directly impacts the vehicle's overall performance and cost effectiveness (Zhang *et al.*, 2019; Li *et al.*, 2020) [16].

- **Automotive Standards and Reliability Considerations**

When integrating GaN based HEMTs into automotive applications, reliability and compliance with automotive standards are of paramount importance. GaN devices must meet rigorous automotive standards for

performance, thermal stability, and long term reliability under challenging operating conditions, such as extreme temperatures, vibrations, and voltage fluctuations. The use of GaN in EVs is still evolving, with ongoing efforts to improve the reliability of these devices to meet the stringent requirements of the automotive industry. As research continues to refine GaN technology and as automotive certification processes evolve, the use of GaN based power electronics in EVs is expected to increase significantly (Zhou *et al.*, 2020; Zhang *et al.*, 2019) [19, 16].

Comparative Performance Analysis

To evaluate the effectiveness of ultra wide bandgap (UWBG) GaN based HEMTs in power electronics applications, a comparative performance analysis against traditional semiconductors such as silicon (Si), silicon carbide (SiC), and standard GaN is essential. Benchmarking based on key performance metrics breakdown voltage, on resistance (R_{on}), switching loss, and thermal resistance provides insight into their advantages in high efficiency systems such as renewable energy converters and electric vehicles.

- **Breakdown Voltage**

Breakdown voltage defines the maximum voltage a semiconductor can withstand without electrical failure. Traditional silicon devices generally support voltages below 600 V, limiting their use in high power, high voltage applications (Jiang *et al.*, 2020) [4]. In contrast, GaN based HEMTs, particularly when built on UWBG platforms like AlGaIn or GaN on SiC, demonstrate breakdown voltages exceeding 1.2 kV. β Ga₂O₃ and diamond devices can theoretically support voltages beyond 3 kV due to their wide bandgaps and high critical electric fields (Higashiwaki & Jessen, 2018; Nomura *et al.*, 2019) [2]. This capability enables more compact and efficient power systems, reducing the number of series connected switches.

- **Switching Loss**

Switching losses, incurred during the transition between ON and OFF states, are critical for determining efficiency in high frequency applications such as DC DC converters and inverters. GaN based HEMTs offer fast switching capabilities with low gate charge and minimal switching losses, especially in high frequency power converters used in solar inverters and EV drives (Li *et al.*, 2022). In comparison, SiC devices switch faster than Si, but not as efficiently as GaN, while UWBG materials like AlGaIn and GaN on Diamond show even lower switching losses due to improved thermal dissipation and reduced parasitics (Shinohara, 2021) [11].

- **Thermal Resistance**

Thermal resistance impacts heat dissipation efficiency. GaN devices, particularly those on SiC or diamond substrates, outperform both Si and SiC in terms of thermal conductivity. Diamond, with its extremely high thermal conductivity (~2000 W/m·K), when used as a substrate for GaN HEMTs, significantly reduces junction temperatures and enhances device reliability under continuous operation (Nakashima *et al.*, 2019). This makes UWBG HEMTs suitable for compact systems where space constraints limit the size of heat sinks or cooling modules.

Table 2: Comparison of Key Performance Metrics

Metric	Silicon (Si)	Silicon Carbide (SiC)	GaN	UWBG GaN based (AlGaN, GaN on Diamond, etc.)
Breakdown Voltage	< 600 V	600–1700 V	~1200 V	> 2000 V
On Resistance (R_{on})	> 100 m Ω ·cm ²	~20–30 m Ω ·cm ²	< 10 m Ω ·cm ²	< 5 m Ω ·cm ²
Switching Loss	High	Medium	Low	Very Low
Thermal Resistance	High	Medium	Low	Very Low (especially GaN on Diamond)
Max Operating Temp.	~150 °C	~200–250 °C	~200 °C	> 300 °C

This comparative analysis underscores the clear advantages of UWBG GaN based HEMTs across all key performance metrics. The combination of high breakdown strength, low on resistance, minimal switching loss, and superior thermal management positions these devices as game changers in both renewable energy and EV powertrain applications. While material cost and fabrication complexity remain challenges, ongoing innovations in substrate engineering (e.g., GaN on SiC, GaN on Diamond) are addressing these barriers and accelerating commercial adoption.

Challenges and Limitations

Despite the remarkable promise of ultra wide bandgap (UWBG) GaN based high electron mobility transistors (HEMTs) in power electronics, several critical challenges hinder their widespread commercialization and integration into high volume markets such as renewable energy and electric vehicles.

Material Challenges

One of the foremost obstacles in developing UWBG devices is the material quality. UWBG materials such as AlGaN, β Ga₂O₃, and GaN on Diamond suffer from inherent material defects, including dislocations, stacking faults, and interface trap states, which degrade device performance and reliability (Pearton *et al.*, 2018) [10]. The doping of UWBG materials, particularly p type doping in GaN and AlGaN, remains a longstanding issue due to deep acceptor levels and compensation effects that limit carrier injection efficiency (Mishra *et al.*, 2017) [8]. Additionally, substrate compatibility especially in GaN on Si or GaN on SiC structures often leads to lattice mismatch and thermal expansion coefficient differences, resulting in strain and defect generation.

Fabrication and Cost Issues

Fabrication of UWBG GaN based HEMTs is another significant challenge. These devices require complex epitaxial growth processes such as molecular beam epitaxy (MBE) or metal organic chemical vapor deposition (MOCVD), which demand stringent control over temperature, pressure, and gas flow to ensure high quality layers. Additionally, achieving high breakdown voltages and low on resistance often necessitates intricate structures like field plates, multiple buffer layers, and advanced gate engineering all of which increase processing time and costs (Li *et al.*, 2019). The cost of high quality substrates such as SiC and synthetic diamond is still high, making the devices less economically competitive with their Si or even SiC counterparts.

Reliability and Long Term Operation

The long term stability of UWBG GaN based HEMTs under harsh operating conditions is a major concern, particularly for automotive and grid tied renewable systems. Issues such as gate leakage, current collapse, and thermal degradation limit device lifetime and require robust passivation and packaging

strategies (Chen *et al.*, 2020) [11]. Moreover, accelerated aging under high temperature and voltage stress has revealed phenomena like trapping effects and breakdown mechanisms that are not yet fully understood, emphasizing the need for more research in reliability physics (Huang *et al.*, 2021) [12].

Lack of Standardization and Design Models

The absence of mature design guidelines and standardization frameworks for UWBG GaN based power devices presents another barrier. While Si and SiC devices benefit from decades of modeling and reliability data, UWBG devices lack comprehensive circuit models that account for their unique switching dynamics and thermal behaviors. This creates difficulties in system level design, simulation, and validation for engineers and hinders adoption in commercial products. Furthermore, testing standards and qualification procedures specific to GaN on Diamond or AlGaN HEMTs are still in early development stages (Shinohara, 2021) [11].

4. Future Directions

As UWBG GaN based HEMTs continue to evolve, several avenues for future research and development emerge. First, there is a pressing need to improve material quality and fabrication yield. Current challenges with defects, doping control, and substrate availability (especially for GaN on diamond and β Ga₂O₃) limit scalability and long term reliability (Pearton *et al.*, 2018; Zhang *et al.*, 2020) [10, 17]. Efforts toward developing low cost, lattice matched substrates and advanced epitaxial growth techniques could significantly enhance device performance and affordability. Second, vertical device architectures and novel packaging strategies remain underexplored. Vertical GaN HEMTs offer higher breakdown voltage and current handling but face issues related to thermal dissipation and fabrication complexity. Integration of high thermal conductivity materials like diamond or advanced composites in packaging and interconnects can alleviate these thermal bottlenecks (Huang *et al.*, 2021) [12].

Furthermore, simulation and modeling tools tailored specifically for UWBG materials are still lacking. Accurate models that capture carrier transport, trapping effects, and thermal behavior under high electric fields are critical for efficient device design and system level optimization. Standardization of testing protocols and lifetime prediction models is also necessary to accelerate commercialization.

On the application side, interdisciplinary studies involving system level integration with renewable energy grids, electric drivetrains, and battery management systems (BMS) can unlock new performance benchmarks. Co design strategies that jointly optimize power converters and semiconductor switches will play a key role in next generation smart energy systems.

Finally, sustainability considerations such as energy usage during fabrication, recyclability, and the environmental impact of exotic materials should be integrated into future design philosophies to align with global green technology

goals.

5. Conclusion

The advancement of ultra wide bandgap (UWBG) materials has marked a transformative shift in the landscape of power electronics, particularly through the development of UWBG GaN based high electron mobility transistors (HEMTs). These devices present a compelling alternative to conventional silicon and even SiC technologies by offering superior breakdown voltage, high electron mobility, reduced on resistance, and remarkable thermal handling capabilities. The integration of UWBG GaN HEMTs into power conversion systems has demonstrated tangible benefits in both renewable energy and electric vehicle applications, including size reduction, efficiency improvements, and enhanced power density (Zhang *et al.*, 2020; Chen *et al.*, 2022)^[17, 1].

While traditional GaN devices have already begun to reshape high frequency and high power applications, UWBG variants leveraging materials like AlGaIn, β Ga₂O₃, and GaN on diamond are poised to further extend these boundaries. Architectural innovations such as vertical HEMTs, gate engineering techniques, field plate structures, and advanced thermal packaging continue to drive improvements in reliability and performance. Comparative analysis against Si and SiC technologies consistently underscores the superior potential of UWBG GaN HEMTs in critical metrics like switching loss, breakdown voltage, and thermal resistance (Pearton *et al.*, 2018; Huang *et al.*, 2021)^[10, 12].

However, to fully realize the commercial viability of these devices, challenges related to material quality, fabrication complexity, cost, and long term reliability must be addressed. Moreover, the lack of standardized models and qualification protocols remains a hurdle to industry wide adoption. Therefore, this review strongly encourages further experimental research into material synthesis, thermal management, and integration strategies, as well as system level evaluations tailored to application specific scenarios in energy and transportation sectors.

UWBG GaN based HEMTs stand at the forefront of next generation power electronics. Their integration into renewable and electric mobility platforms has the potential to revolutionize energy systems by achieving unprecedented efficiency and sustainability benchmarks. Continued interdisciplinary collaboration between materials scientists, electrical engineers, and system designers will be critical in bridging current gaps and accelerating the widespread deployment of these advanced semiconductor devices.

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